

Resistive

I.Laktineh

IPN-Lyon

Motivation

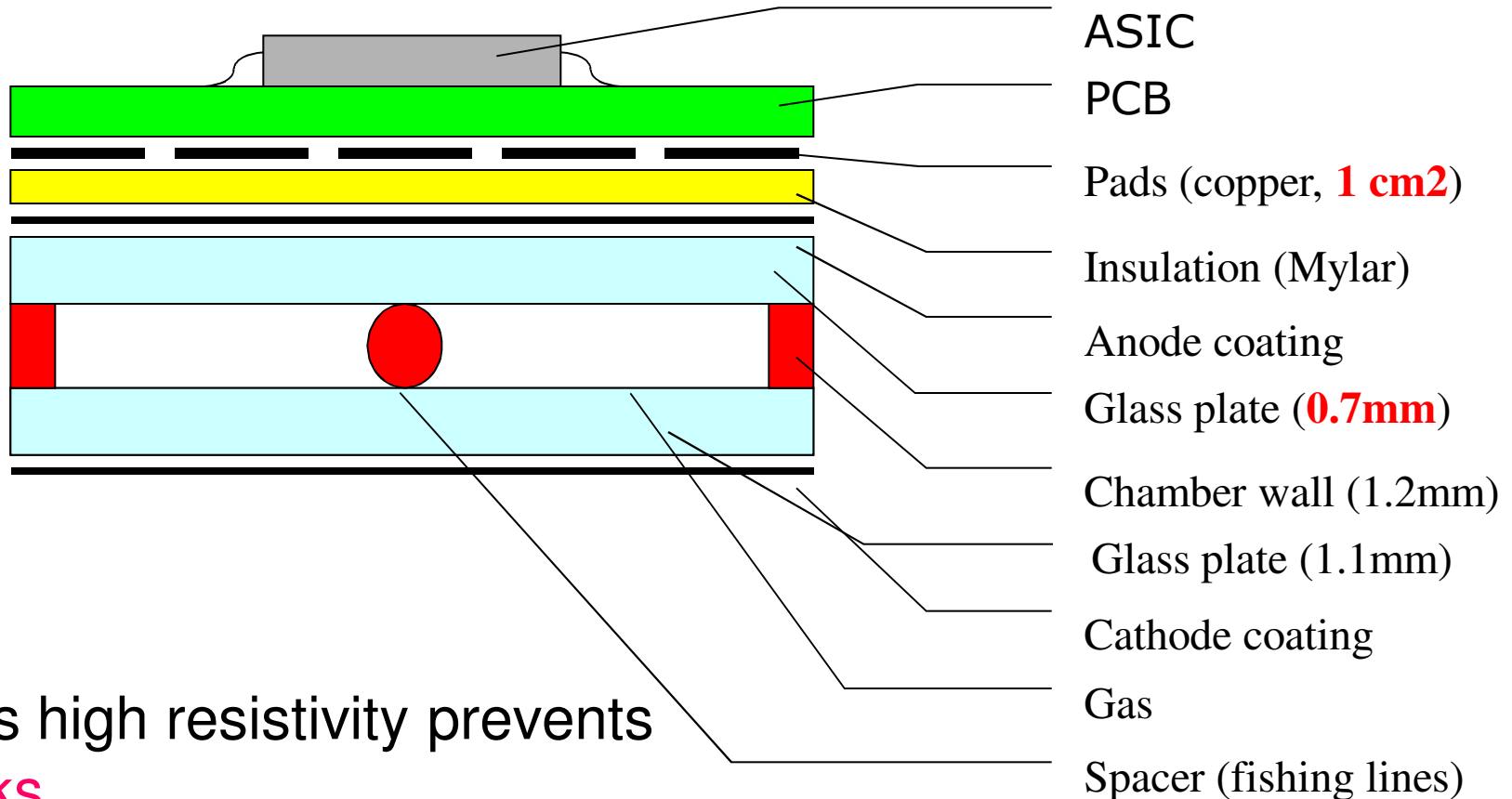
Calorimeters are expected to play an important role in future experiments (ILC, CLIC...) based on PFA concepts → high granularity is needed

→ Gas detectors can provide a suitable sensitive medium :Homogeneous,
→ Granularity provided by the electronics readout

Solutions : **RPC**, GEM, **MICROMEGAS**.

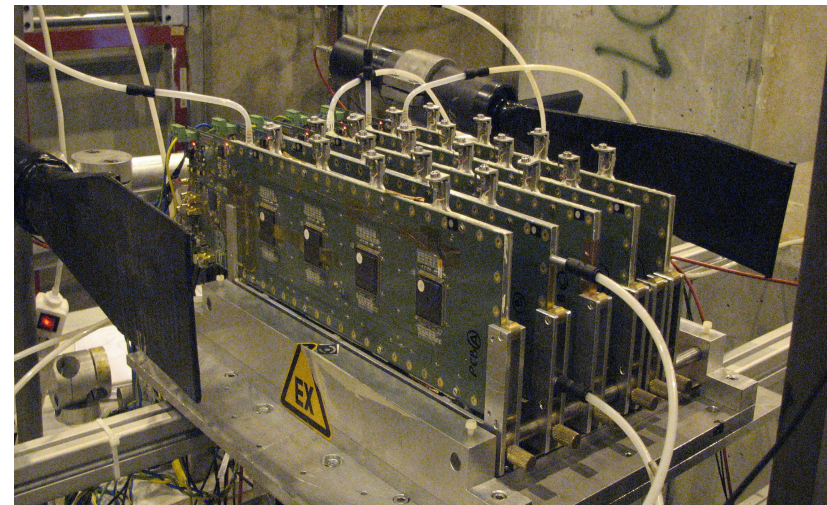
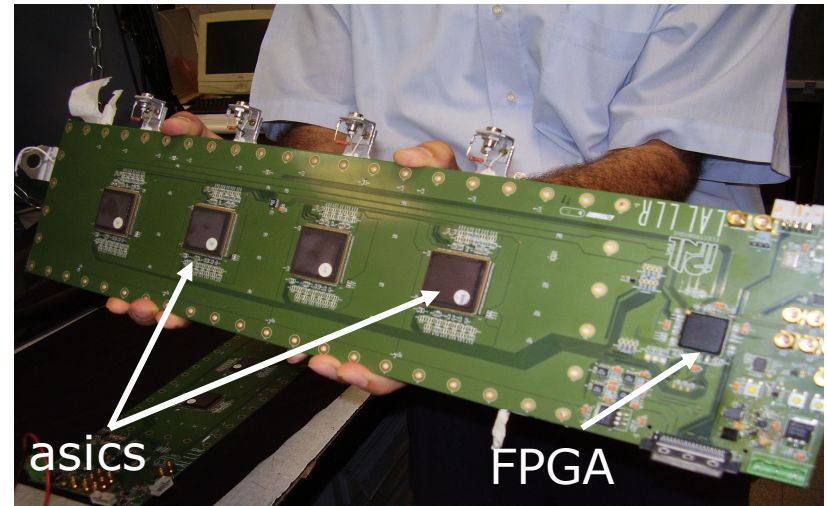
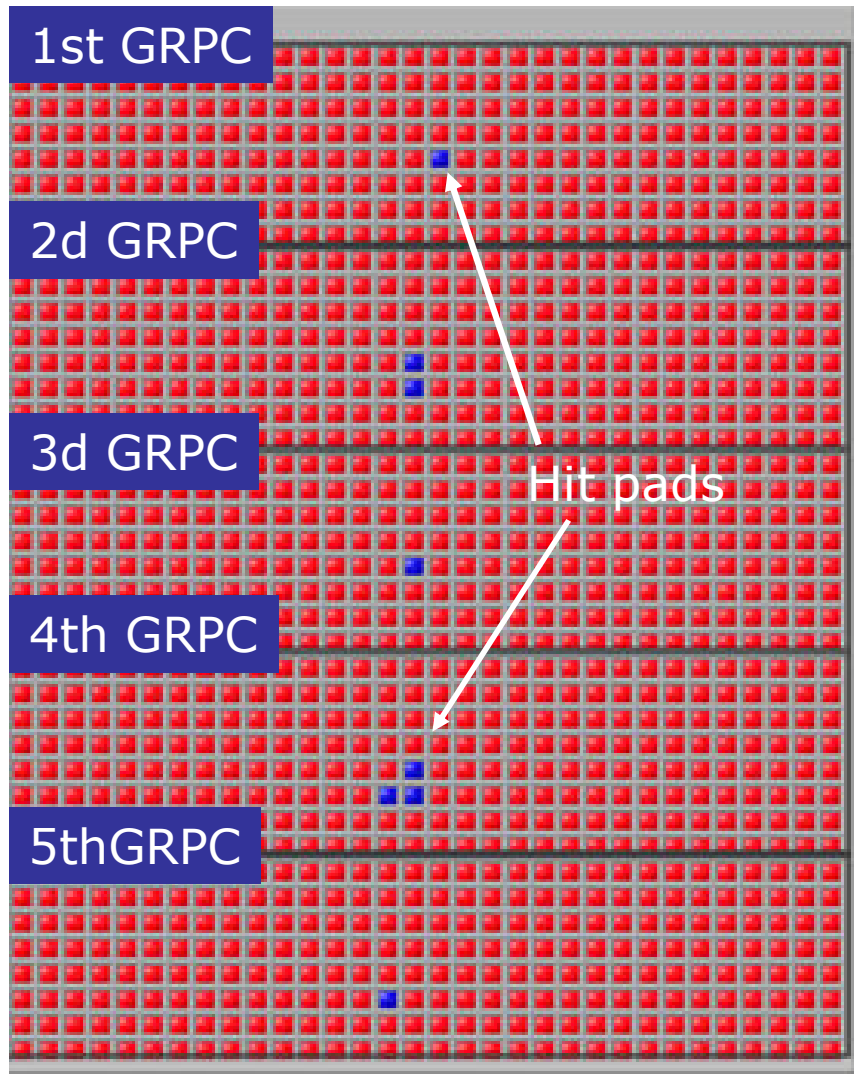
GRPC for the DHCAL

- Thickness of few millimeters
- Efficient, homogenous, cheap and easy to build



Glass high resistivity prevents
sparks

Small GRPCs (32X8 pads) were built and tested with success using semi-digital electronics

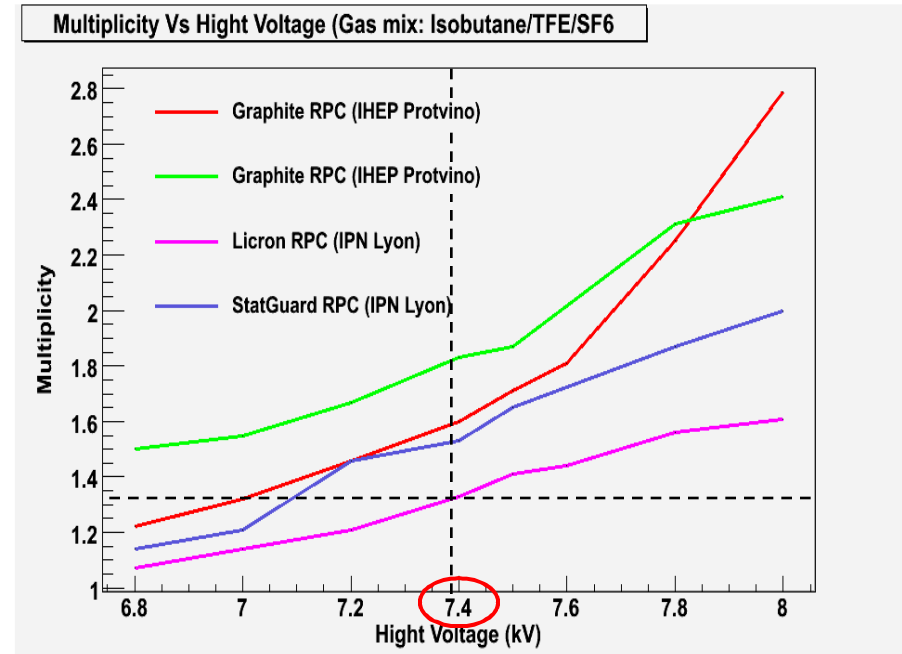
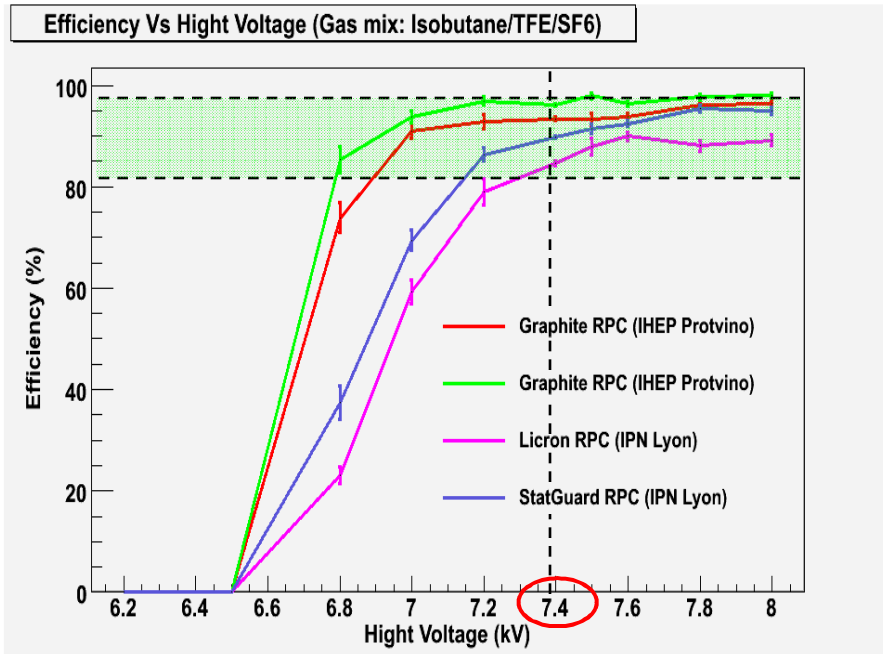


Resistive painting is used to establish HV

Graphite 400 K Ω/\square

Licron : > 20 M Ω/\square

Statguard few M Ω/\square



The problem is to have homogenous painting for large surface:

Graphite (400 K Ω/\square) Standard but high multiplicity

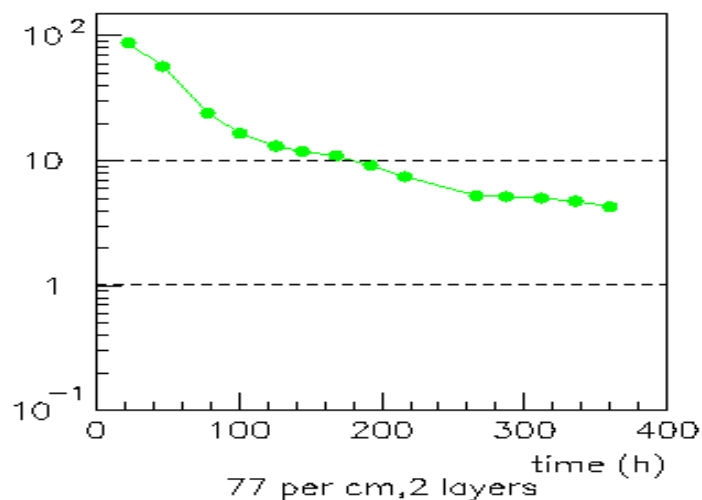
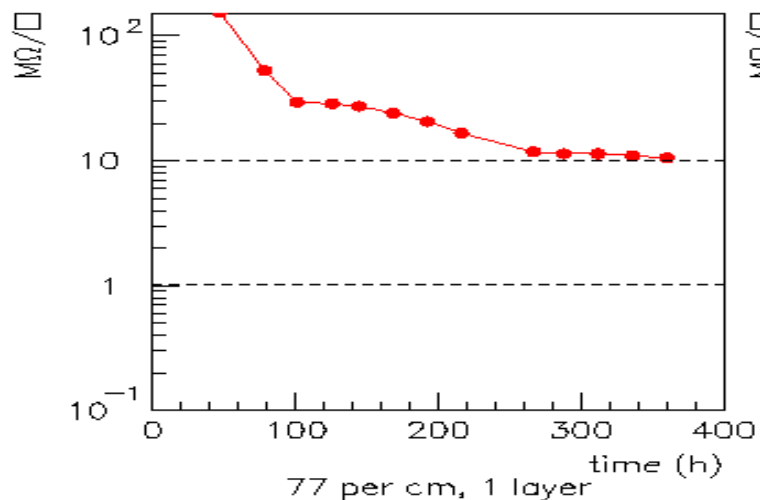
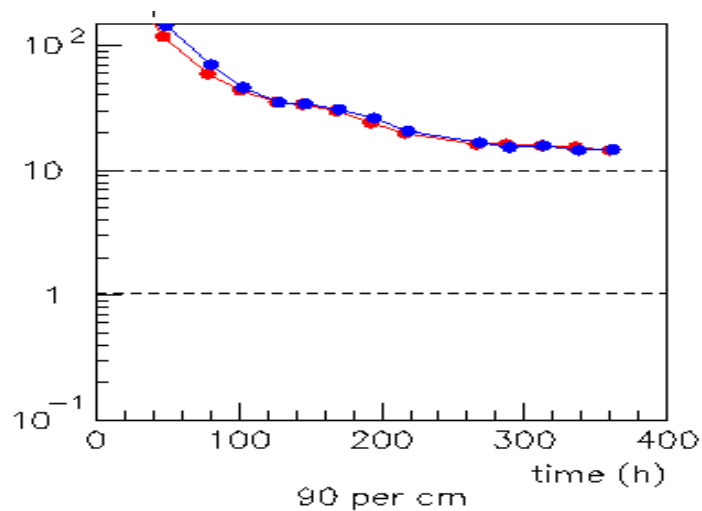
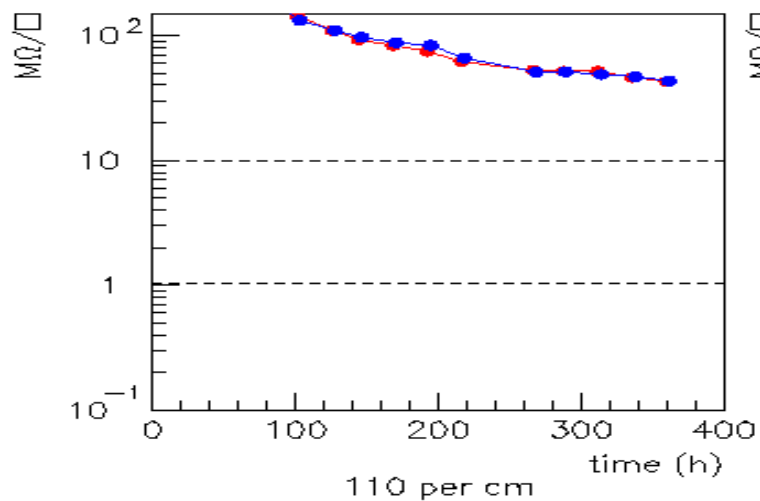
Licron (> 20 M Ω/\square) : Spray, good multiplicity, HV long-term connection problems (HV lost after few months)

Statguard (few M Ω/\square) : Liquid painting, stable, no HV connection problem observed so far but homogeneity is not good when painted with a roll

Silk Screen Printing :

The technique is well known , it provides homogenous and well controlled coating. Simple tools are needed

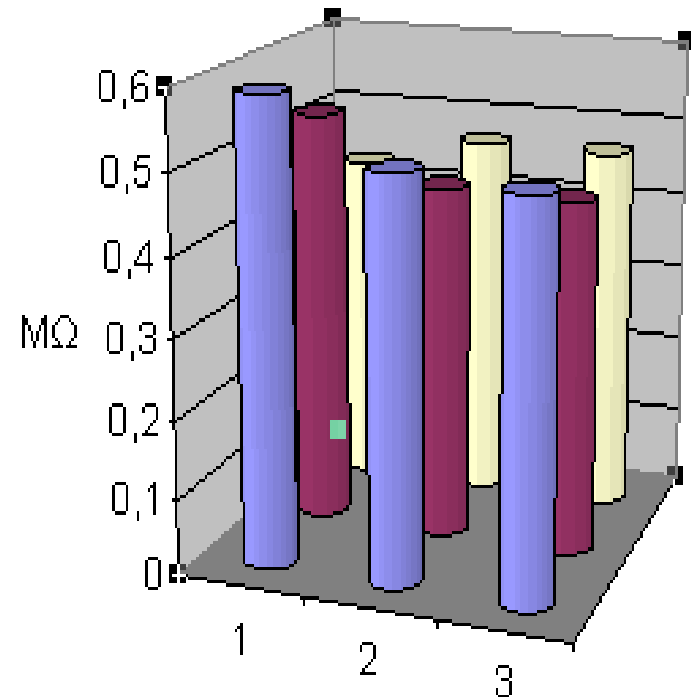
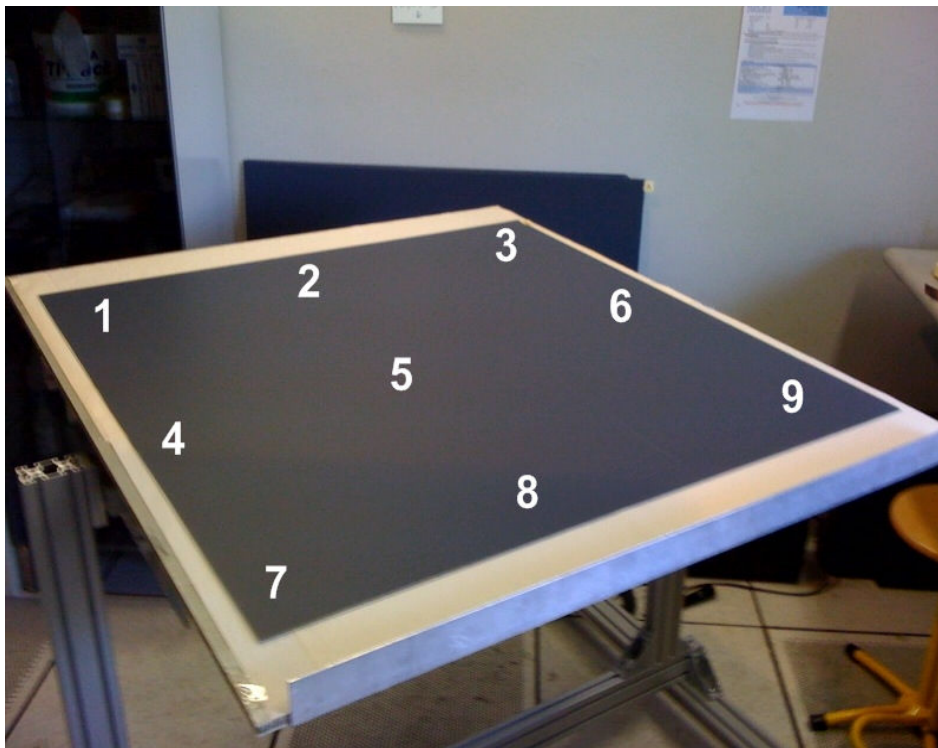


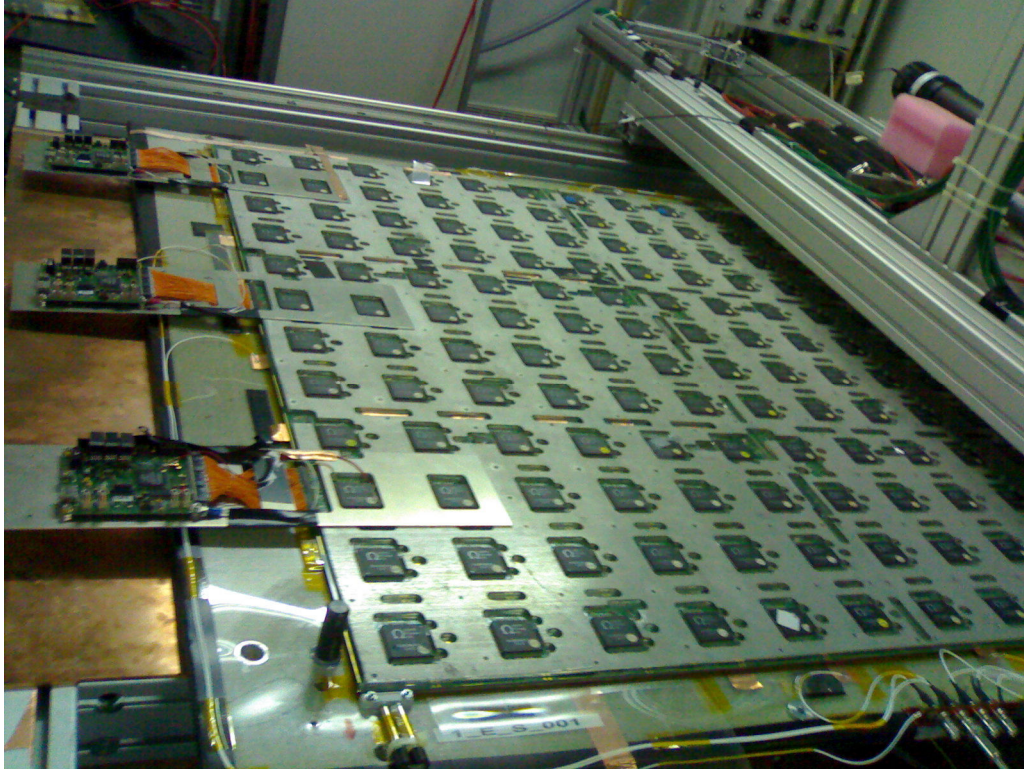


Silk Screen Printing :

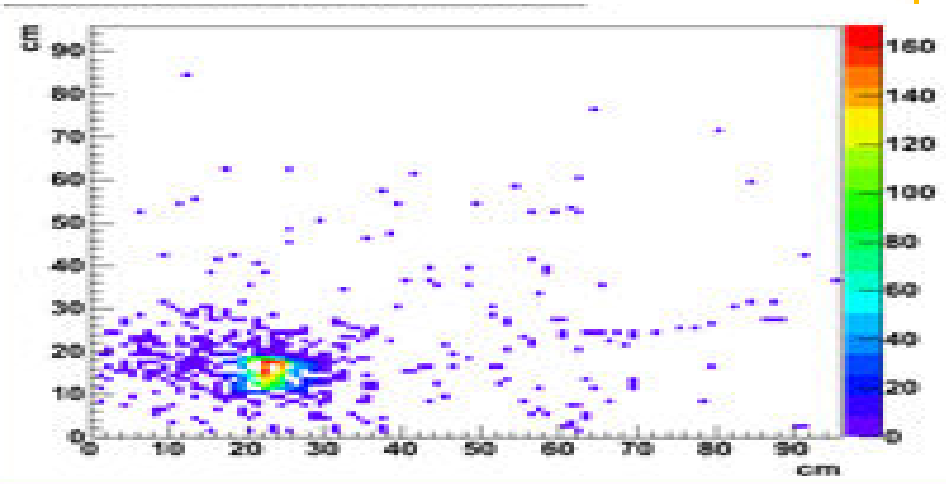
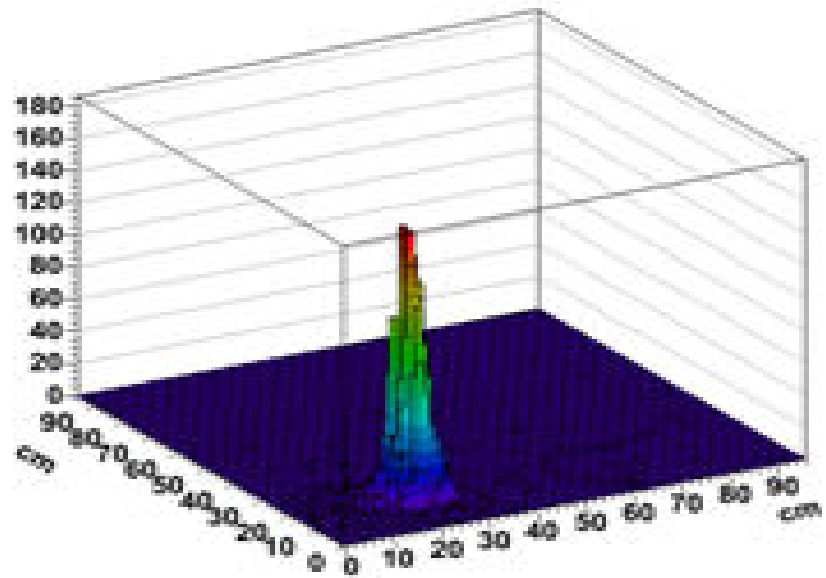
Statguard is not really adapted to Silk Screen Printing. It dries quickly

Colloidal graphite ($\sim 1 \text{ M } \Omega / \square$) is well suited for Silk Screen Printing but drying at high temperature (180°) is needed

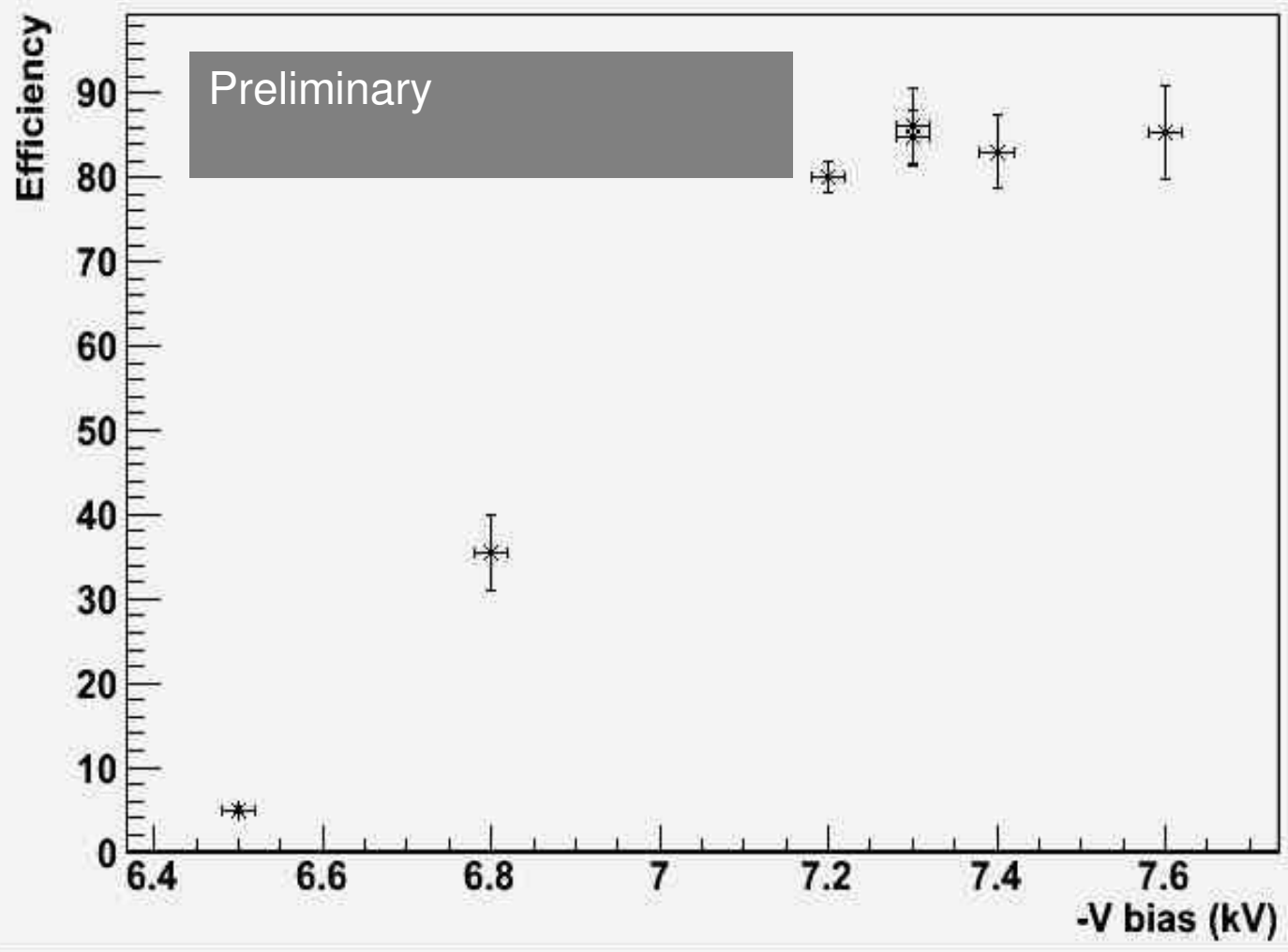




Beam profile in 1 m² chamber



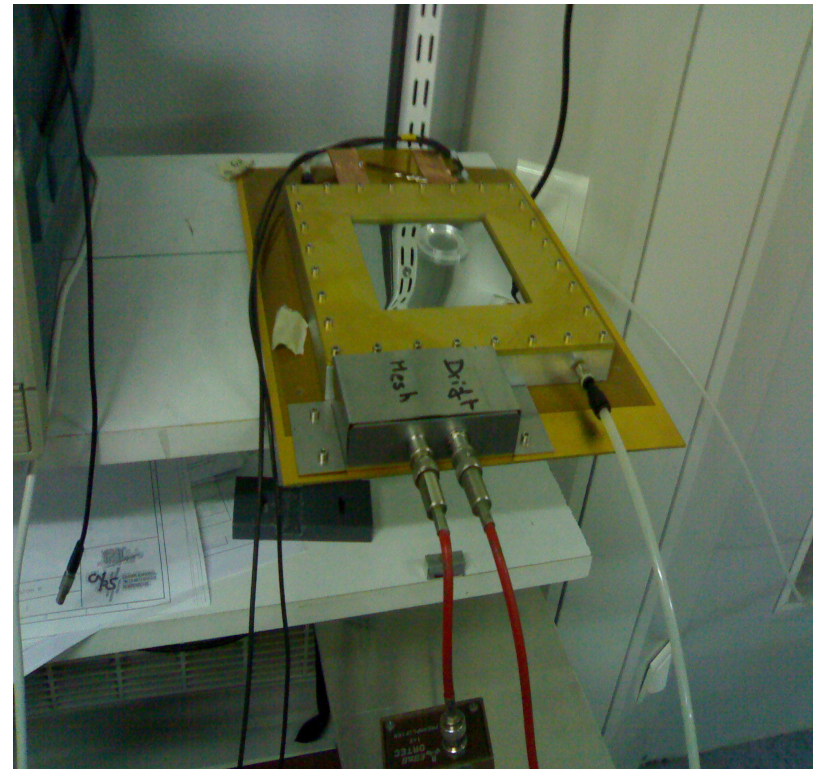
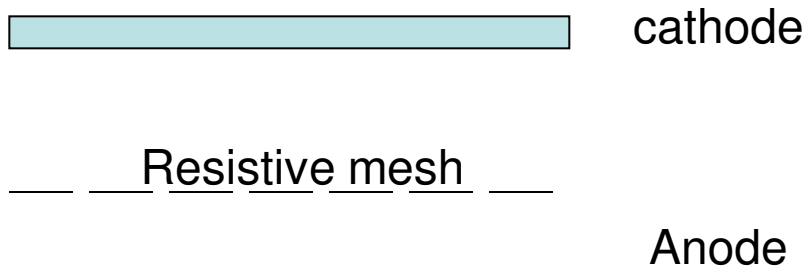
Graph

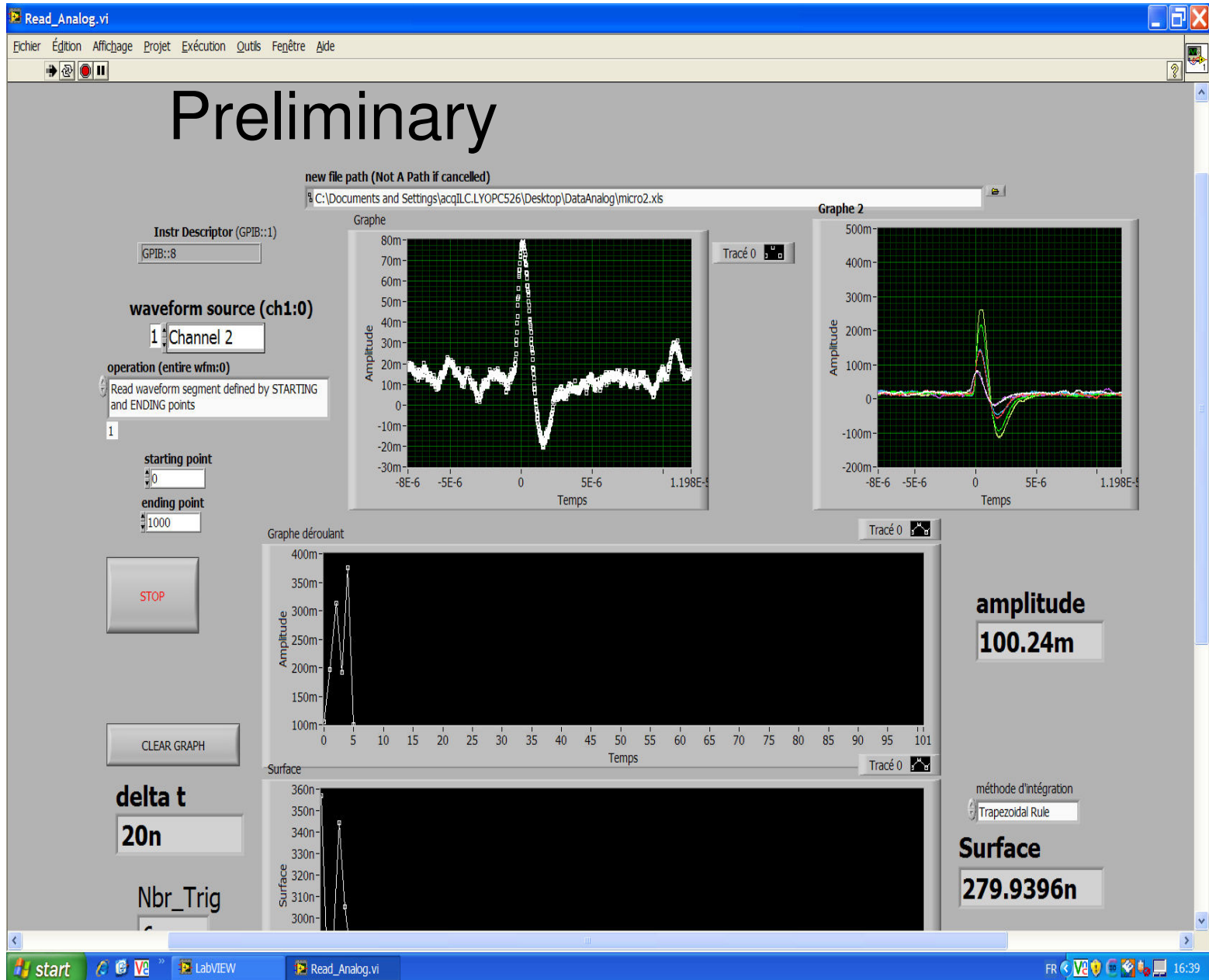


Why not combining RPC and Micromegas

For large Micromegas (not segmented) discharge can be a problem for electronics. This can be avoided by adopting the RPC principle

- 1- Resistive anode
- 2- Resistive mesh : few M Ω .cm Kapton holes made with LASER (collaboration with Rui)





Signal obtained from the mesh: Pream ORTEC142B+AMPLIFIER(gain=20)

Conclusion

- Resistive material control is of an utmost importance.
- Expertise from RPC can be helpful in Micromegas
- Resistive Mesh is an attempt to overcome discharge problems